



JPW

In re application of:
Walter SCHWARZENBACH et al.

Confirmation No.: 7150

Application No.: 10/716,612

Group Art Unit: 2813

Filing Date: November 20, 2003

Examiner: Thanhha S. Pham

For: ANNEALING PROCESS AND DEVICE
OF SEMICONDUCTOR WAFER

Attorney Docket No.: 4717-7700

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

In response to the office action dated May 3, 2005, please enter the following amendments and comments into the file of this application.

Amendments to the claims are reflected in the complete listing of all claims which begins on page 2 of this paper.

Remarks begin on page 5 of this paper.

No fee is believed to be due for the claim changes of this submission. Please charge any required fees to Winston & Strawn Deposit Account No. 50-1814.